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Electronic Version v1.1

Stylesheet Version v1.1.0

Title of Invention	METHOD FOR IMAGE REVERSAL OF IMPLANT RESIST USING A SINGLE PHOTOLITHOGRAPHY EXPOSURE AND STRUCTURES FORMED THEREBY	
Application Number :		
Date :		
First Named Applicant: Steven J. Holmes		
Confirmation Number:		
Attorney Docket Number: FIS920030151US2		
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Submitted By: Sean F. Sullivan Registered Number: 38,328	Elec. Sign. SFS	Sign. Capacity Attorney

Documents being submitted:	Files
us-fee-sheet	epave-usfees.xml us-fee-sheet.xsl us-fee-sheet.dtd
us-ids	epave-usidst.xml us-ids.dtd us-ids.xsl
us-request	epave-usrequ.xml us-request.dtd us-request.xsl
application-body	specification-trans.xml us-application-body.xsl application-body.dtd wipo.ent mathml2.dtd mathml2-qname-1.mod isoamsa.ent isoamsb.ent isoamsc.ent isoamsn.ent isoamso.ent isoamsr.ent isogrk3.ent isomfrk.ent isomopf.ent isomscr.ent isotech.ent isobox.ent isocyr1.ent isocyr2.ent isodia.ent isolat1.ent isolat2.ent isonum.ent isopub.ent mmlextra.ent mmlalias.ent soextblk.dtd figures1abcd.tif figures1efgh.tif figures2abcd.tif figures2e3ab.tif
us-declaration	declarationp1.tif
us-declaration	declarationp2.tif
us-declaration	declarationp3.tif
us-declaration	declarationp4.tif
us-declaration	declarationp5.tif
Comments	